

for 10/695,798

Freeform Search

Database:	US Pre-Grant Publication Full-Text Database	
	US Patents Full-Text Database	
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	EPO Abstracts Database	
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	Derwent World Patents Index	
Term:	IBM Technical Disclosure Bulletins	
	20020040847 and (etch\$4 or pattern\$4 or resist or photoresist or mask or masking)	
Display:	10	Documents in Display Format: CIT
Generate:	<input type="radio"/> Hit List <input checked="" type="radio"/> Hit Count <input type="radio"/> Side by Side <input type="radio"/> Image	

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DATE: Thursday, March 10, 2005 [Printable Copy](#) [Create Case](#)

<u>Set</u> <u>Name</u> side by side	<u>Query</u>	<u>Hit</u> <u>Count</u>	<u>Set</u> <u>Name</u> result set
	DB=PGPB; PLUR=YES; OP=ADJ		
<u>L3</u>	20020040847 and (oxidiz\$4 or oxidation)	1	<u>L3</u>
<u>L2</u>	20020040847 and (etch\$4 or pattern\$4 or resist or photoresist or mask or masking)	1	<u>L2</u>
<u>L1</u>	20020040847 and (kr or krypton or trench\$2 or isolation or (gate adj (oxide or dielectric)))	1	<u>L1</u>

END OF SEARCH HISTORY

		(word adj line)	03-05 11:52:35
<u>S11364</u>	<u>U</u>	JPAB	
		(word adj line)	2005-
		same nitride	03-05 11:51:08
<u>S11363</u>	<u>U</u>	JPAB	
		word adj line	2005- 03-05 11:50:48
<u>S11362</u>	<u>U</u>	TDBD	
		(gate same (word adj lline))	2005- 03-05 11:50:36
<u>S11361</u>	<u>U</u>	PGPB	
		(gate same (word adj lline))	2005- 03-05 11:50:27
<u>S11360</u>	<u>U</u>	USPT	
		(gate same (word adj lline))	2005- 03-05 11:50:19
<u>S11359</u>	<u>U</u>	PGPB,USPT	
		(20020040847 or 6391803) and ((gate adj insulation) or trench\$2 or fox or isolation)	2005- 03-03 15:20:13
<u>S11358</u>	<u>U</u>	PGPB,USPT	
		(20020040847 or 6391803) and (gate or trench\$2 or fox or isolation)	2005- 03-03 15:18:59
<u>S11357</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	
		("sio.sub.2" or oxide or nitride or oxynitride or sion or sin) same densification same (("o.sub.2" or oxygen) adj plasma)	2005- 03-03 14:06:10
<u>S11356</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	
		("sio.sub.2" or oxide or nitride or oxynitride or sion or sin) same densification same plasma	2005- 03-03 14:05:23
<u>S11355</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	
		20050009281 and (cvd or lpcvd or pecvd)	2005- 03-03 14:03:00
<u>S11354</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	
		6649538 and (cvd or lpcvd or pecvd)	2005- 03-03 14:01:36
<u>S11353</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD	
		(lpcvd adj1	2005-

		(oxide or nitride or oxynitride or sion or sin or "sio.sub.2")) same (("o.sub.2" or oxygen) adj1 plasma) same (treating or treatment or exposing or exposure)	03-03 14:00:37
<u>S11352</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (cvd adj1 (oxide or nitride or oxynitride or sion or sin or "sio.sub.2")) same (("o.sub.2" or oxygen) adj1 plasma) same (treating or treatment or exposing or exposure)	2005-03-03 13:56:43
<u>S11351</u>	<u>U</u>	PGPB	20040147137 and ((ald or (atomic adj layer adj deposition)) same plasma)
<u>S11350</u>	<u>U</u>	PGPB	20040147137 and (ald or (atomic adj layer adj deposition)) same plasma
<u>S11349</u>	<u>U</u>	PGPB	20040166652 and (screen and plate and frame)
<u>S11348</u>	<u>U</u>	PGPB	20030059690 and (frame and screen and plate)
<u>S11347</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD (flow adj path) same (frame near4 (screen or plate)) same (depression or opening or convacity or cavity) same groove\$1	2005-03-03 10:29:18
<u>S11346</u>	<u>U</u>	PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD ((channel\$1 or	2005-